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**S3S Conference
2.5/3D Technology and
Commercialization**

October 11, 2016

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WHAT ARE THE DRIVERS OF CHANGE?

Precipitating Events for Change

FALLOUT FROM A FIRE: CHIP PRICES SOAR

The Washington Post

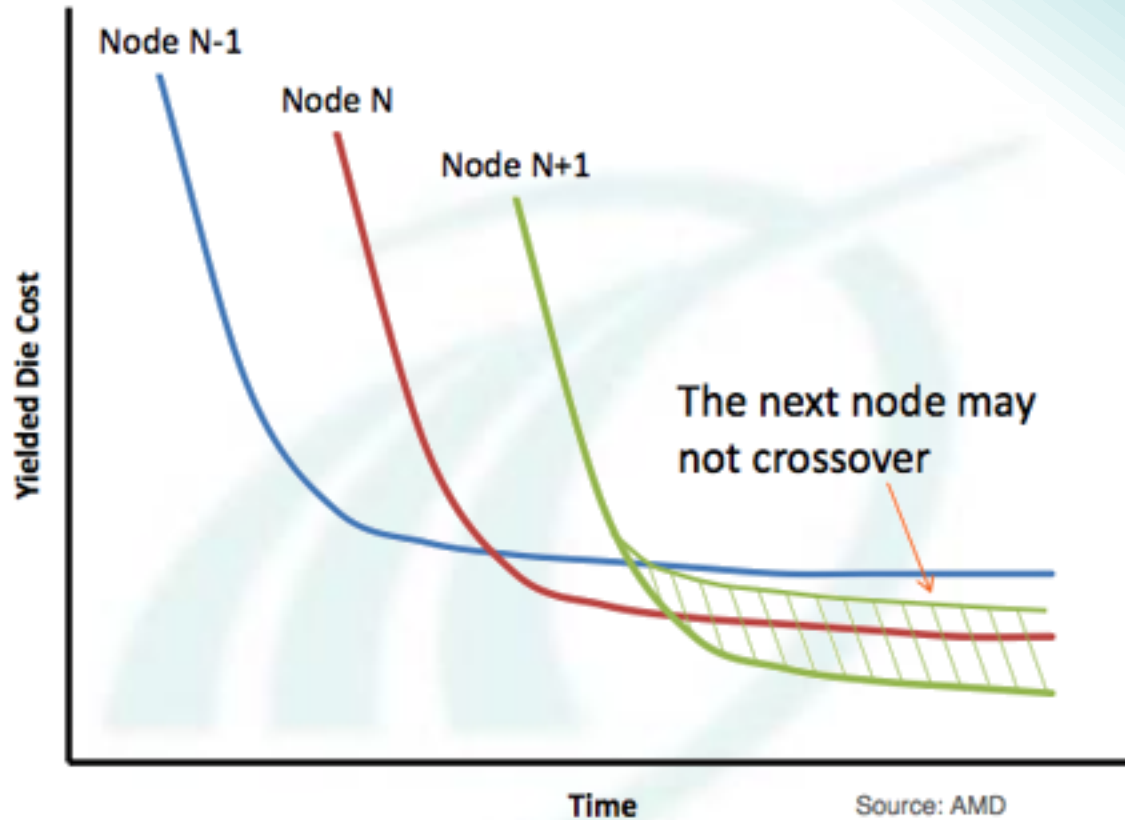
By John Mintz July 22, 1993

Prices on some computer memory chips have almost doubled in recent weeks, and one reason is an explosion at a Japanese plastics factory that makes a compound used in the chips. But some computer industry executives say the prices probably will drop as fast as they rose once alternative sources for the plastic are found.

The July 4 fire destroyed the Sumitomo Chemical Co. plant in Nihama, which supplies 60 percent of the epoxy resin used to manufacture DRAM -- dynamic random access memory -- computer chips.

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Expiring Economics

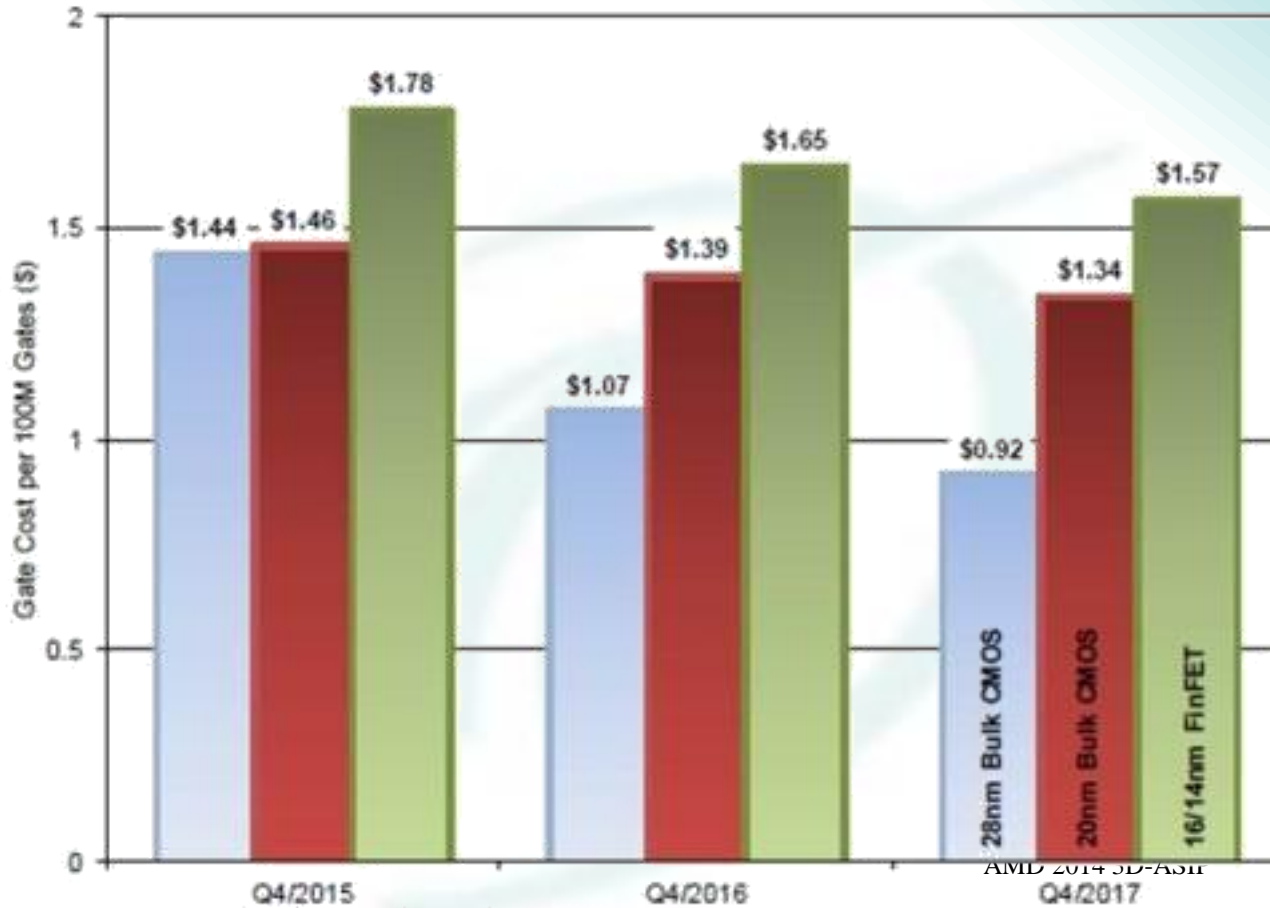


Source: AMD

AMD 2014 3D-ASIP

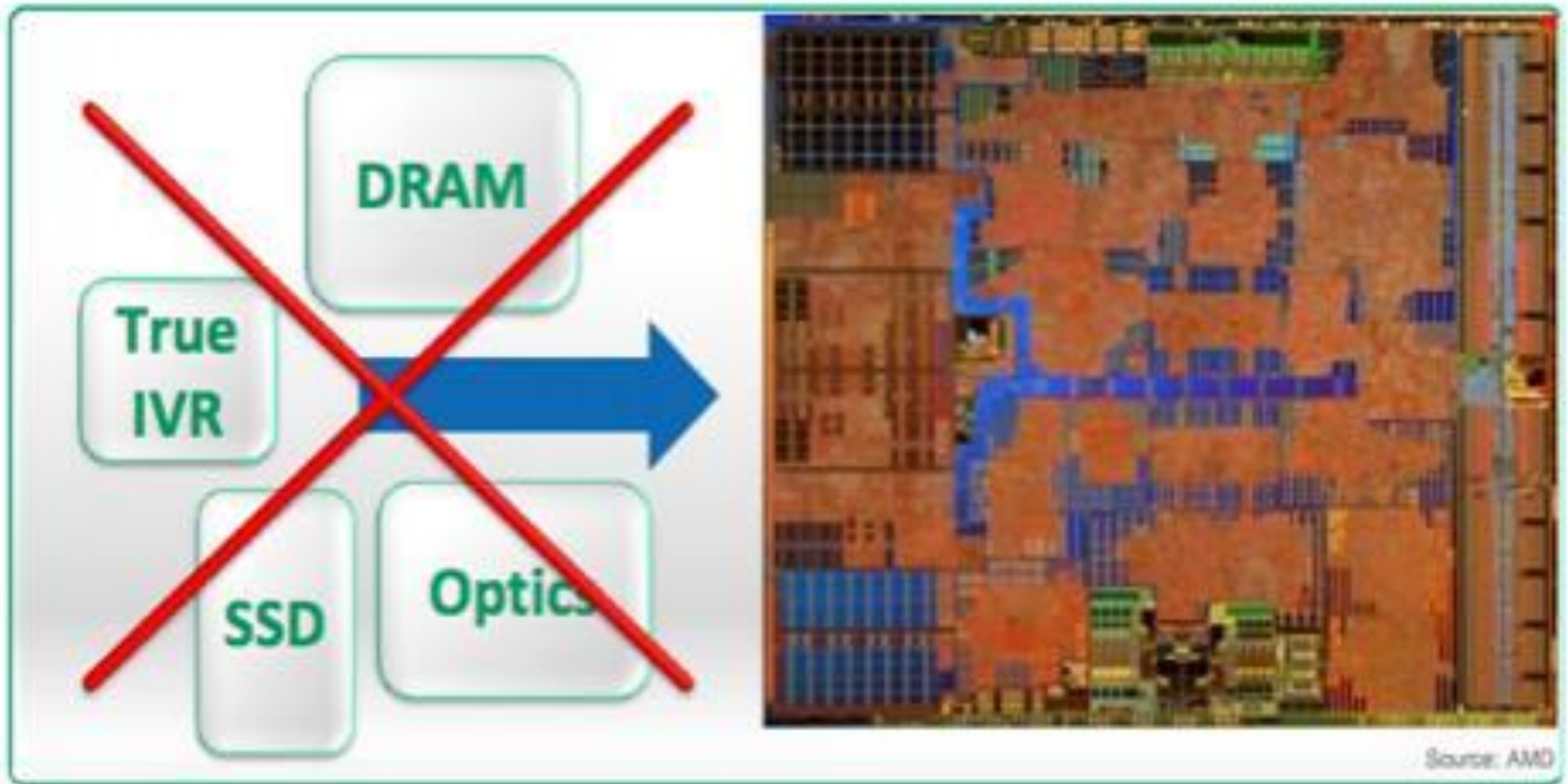
Cost Trend Reversal

Gate Costs for Bulk CMOS and FinFET



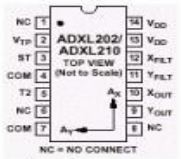
Source: International Business Strategies, Inc.

The Apples & Oranges of SOC



AMD 2014 3D-ASIP

Internet Of Things



Accelerometer



Gyro



Pendulum Resistive Tilt Sensors



Piezo Bend Sensor



Metal Detector



Gas Sensor



Gieger-Muller Radiation Sensor



Pyroelectric Detector



UV Detector



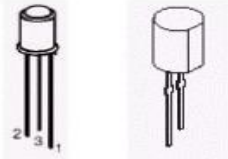
Resistive Bend Sensors



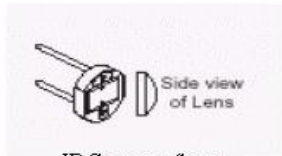
Digital Infrared Ranging



CDS Cell Resistive Light Sensor



IR Pin Diode



IR Sensor w/lens



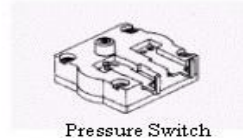
Limit Switch



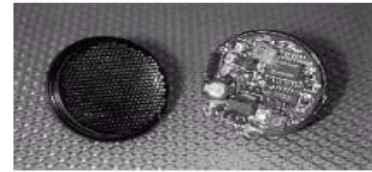
Mechanical Tilt Sensors



Touch Switch



Pressure Switch



Miniature Polaroid Sensor



IR Reflection Sensor



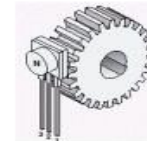
IR Amplifier Sensor



Thyristor



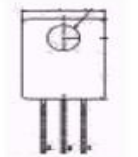
Magnetic Sensor



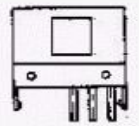
Hall Effect Magnetic Field Sensors



Polaroid Sensor Board



Lite-On IR Remote Receiver



Radio Shack Remote Receiver



IR Modulator Receiver



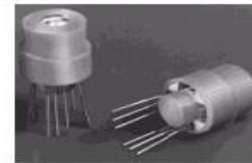
IRDA Transceiver



Solar Cell



Compass



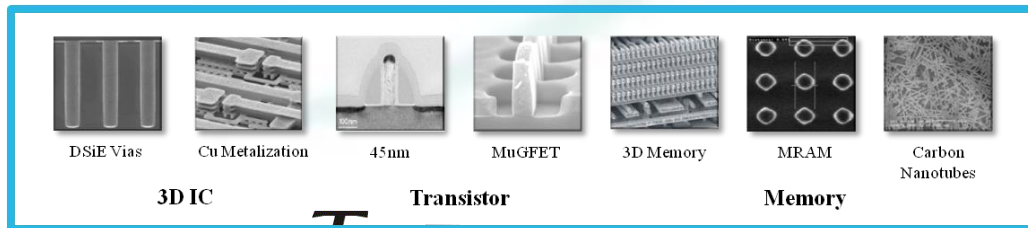
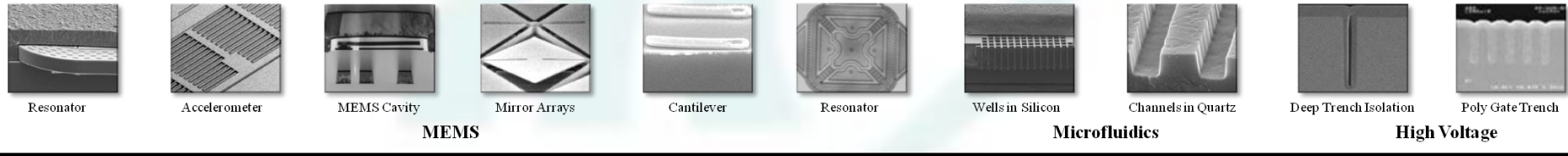
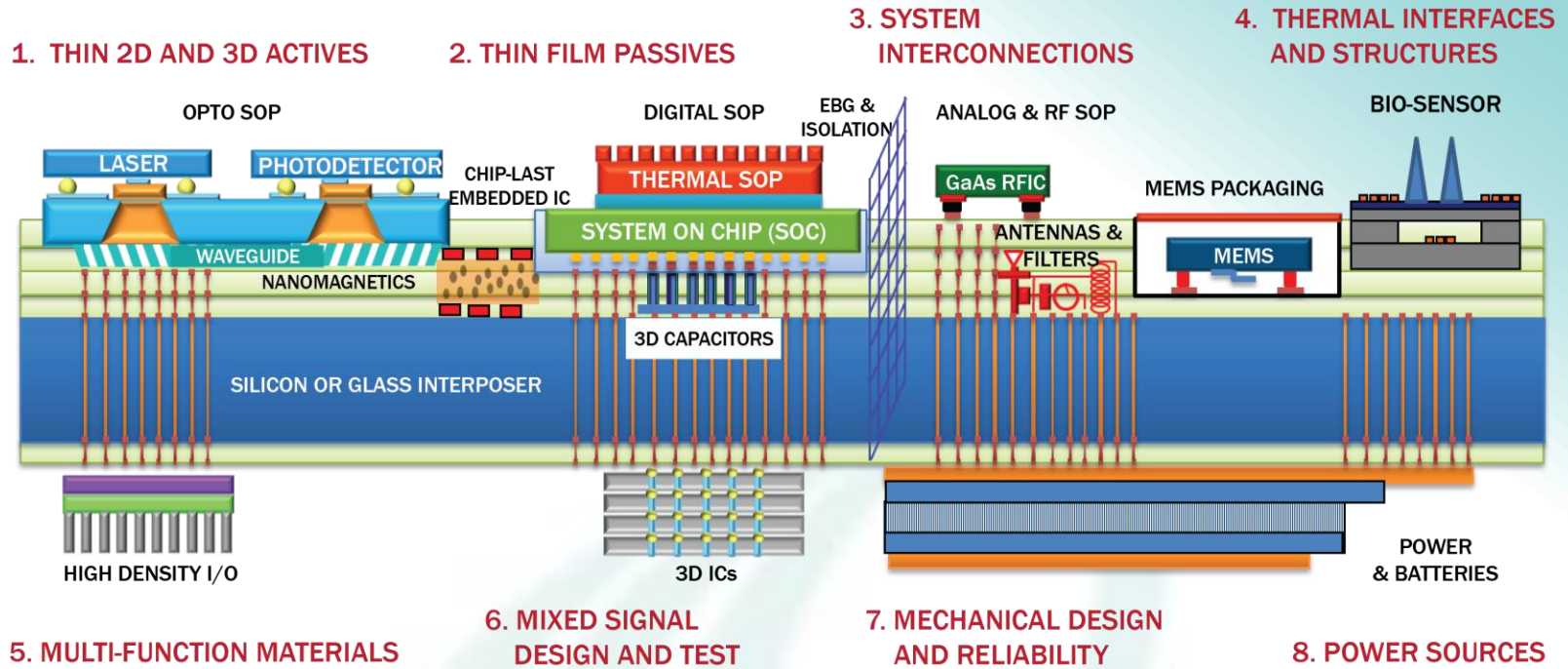
Compass



Piezo Ultrasonic Transducers

Societyofrobots.com

More Than Moore





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MORE THAN MOORE

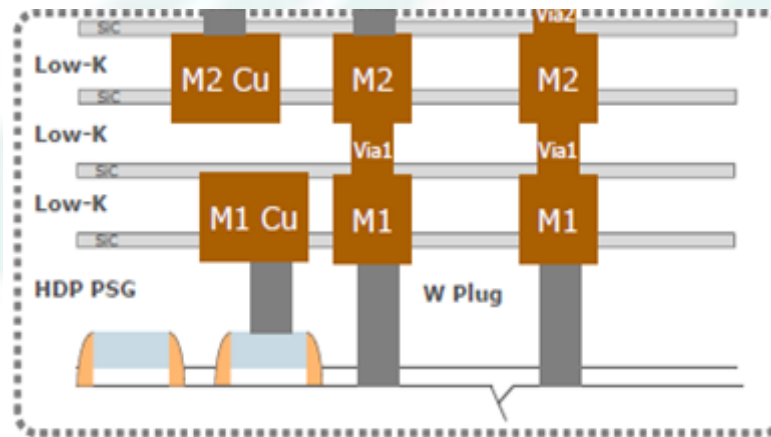
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The Fabrication Road to More Than Moore

Memories, CMOS, Photonics, III-V,
Novel Materials, Microfluidics, MEMS,
etc.

Build novel
structures BEOL

Start with FEOL
CMOS wafer



Integration Paths: Additive Silicon and 2.5/3D

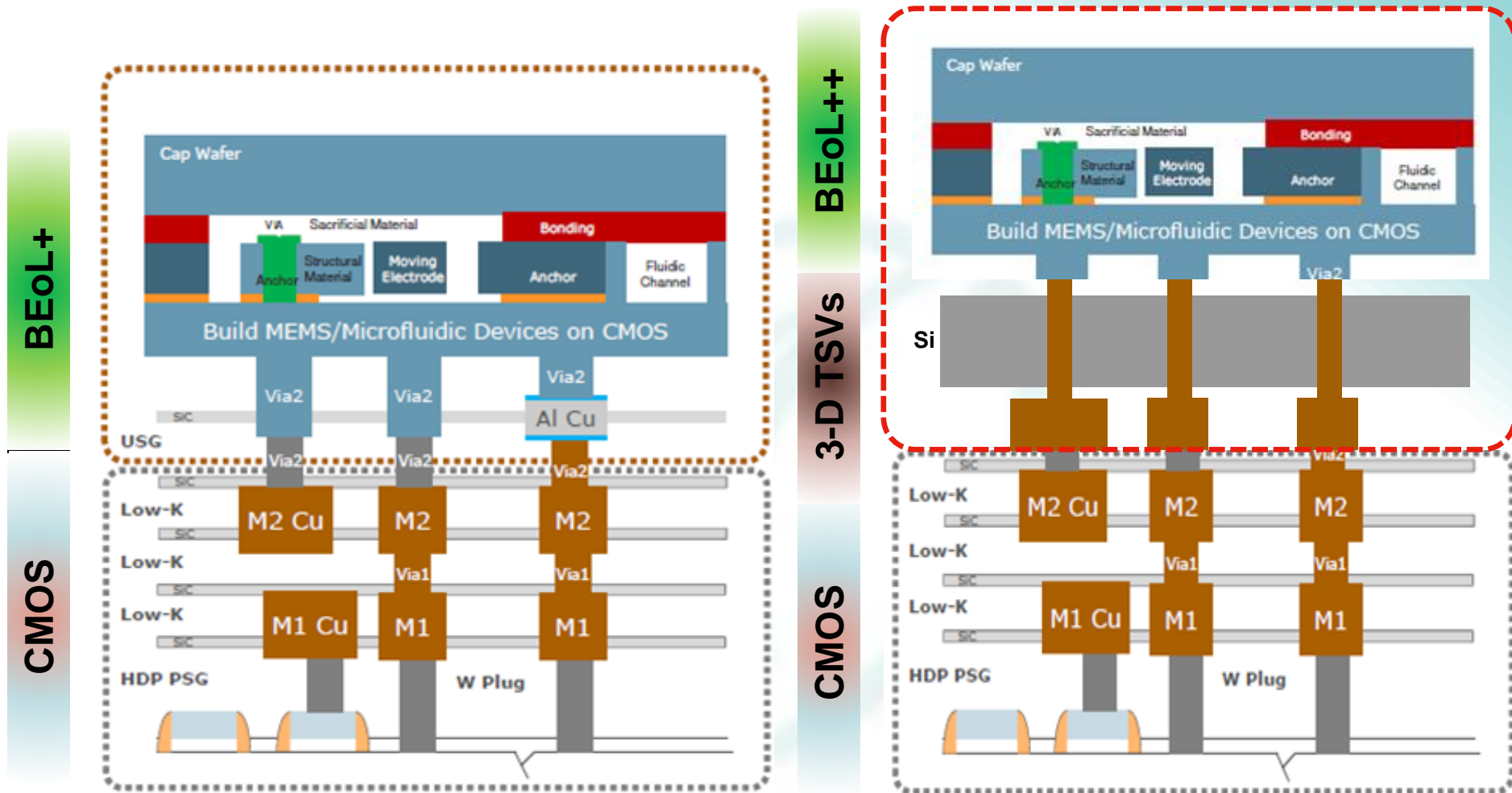
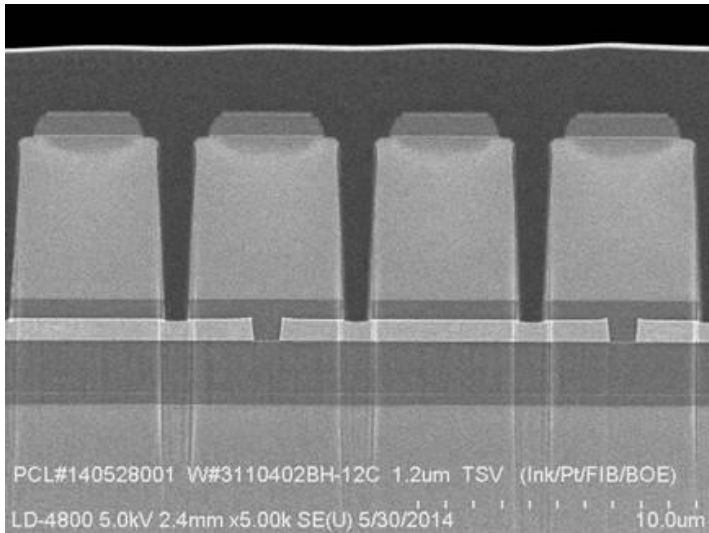


Figure 1: Non-digital devices built directly on CMOS (left), or built separately and joined through 3-D TSVs

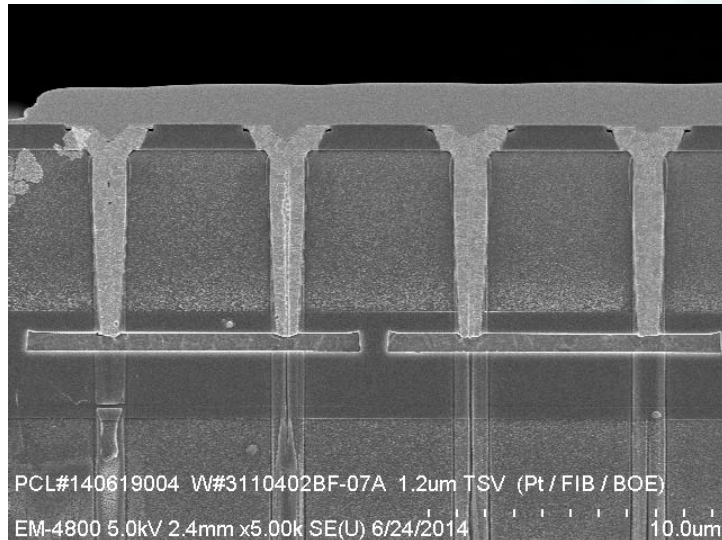

New Elements Introduced to Fabrication

Typical CMOS Fab										Additional at Novati											
H																	He				
Li	Be											B	C	N	O	F	Ne				
Na	Mg											Al	Si	P	S	Cl	Ar				
K	Ca	Sc	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn	Ga	Ge	As	Se	Br	Kr				
Rb	Sr	Y	Zr	Nb	Mo	Tc	Ru	Rh	Pd	Ag	Cd	In	Sn	Sb	Te	I	Xe				
Cs	Ba	La	Hf	Ta	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn				
Fr	Ra	Ac	Rf	Db	Sg	Bg	Hs	Mt													
		Ce	Pr	Nd	Pm	Sm	Eu	Gd	Tb	Dy	Ho	Er	Tm	Yb	Lu						
		Th	Pa	U	Np	Pu	Am	Cm	Bk	Cf	Es	Fm	Md	No	Lr						

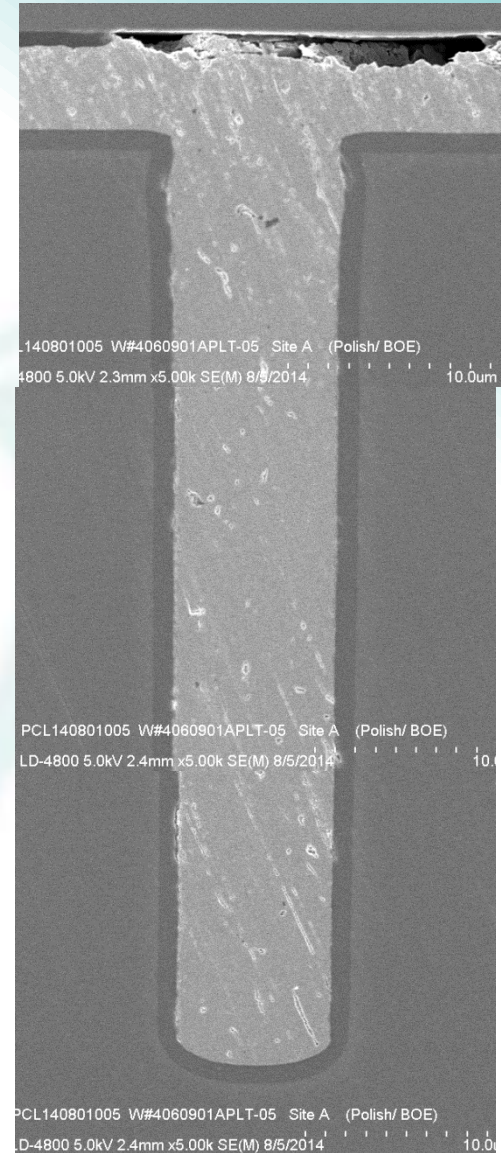
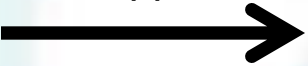
TSV Insertion to Create 2.5/3D Assemblies



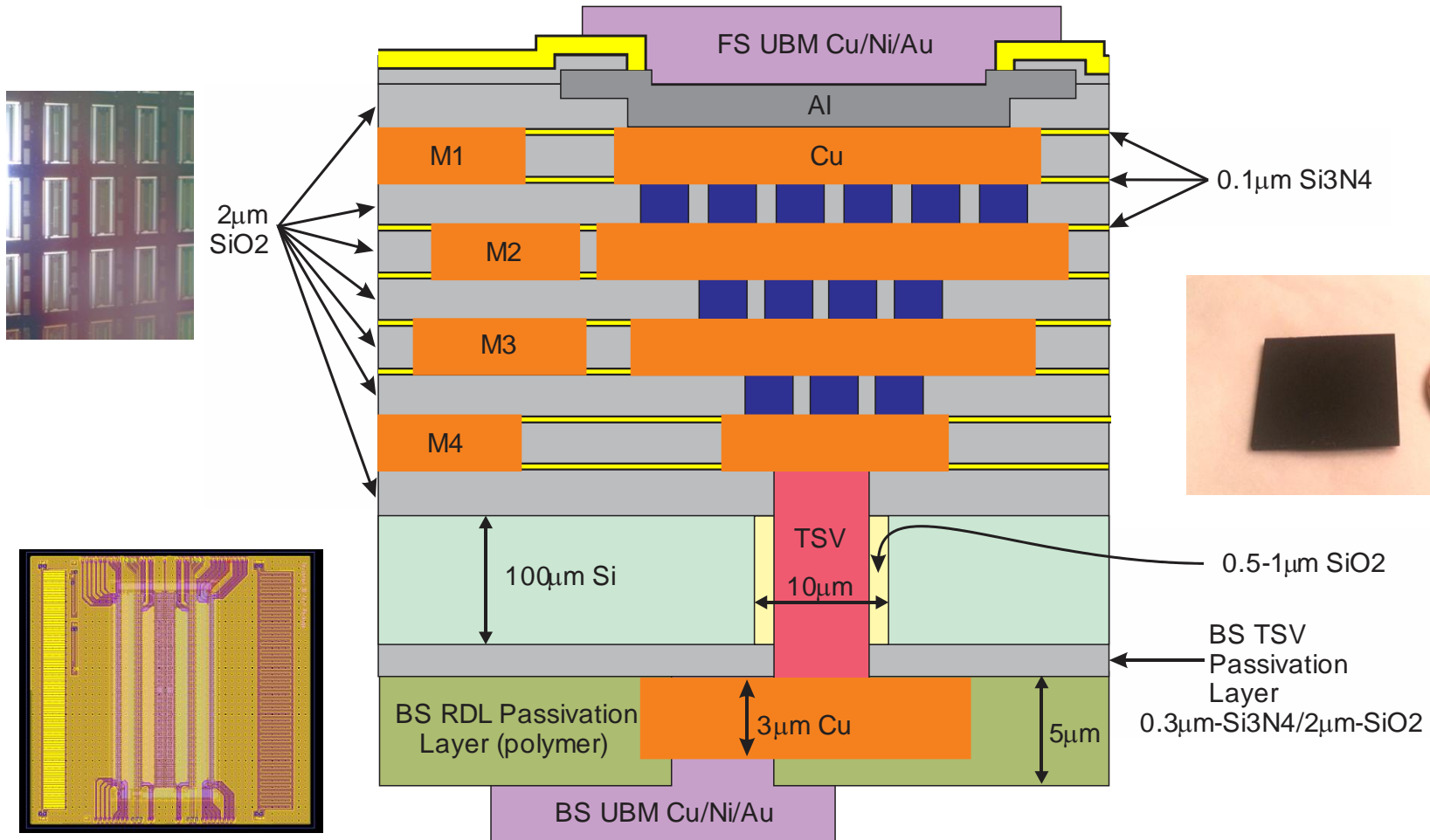
1.2x6um
Tungsten



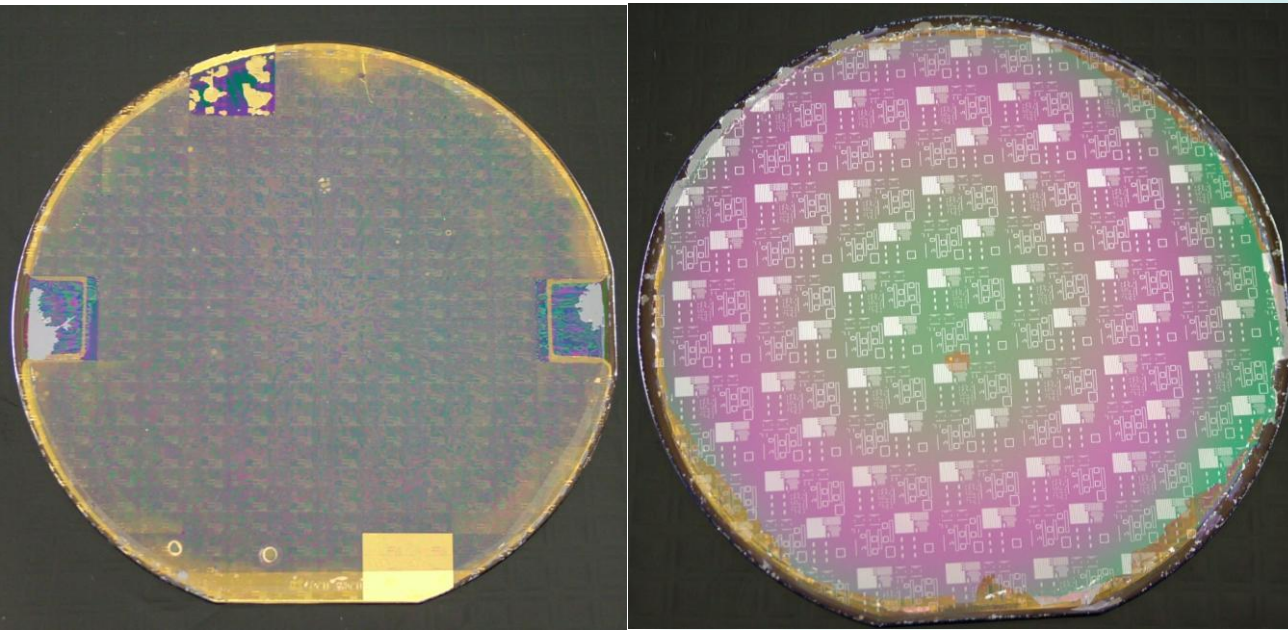
10x100um
Copper



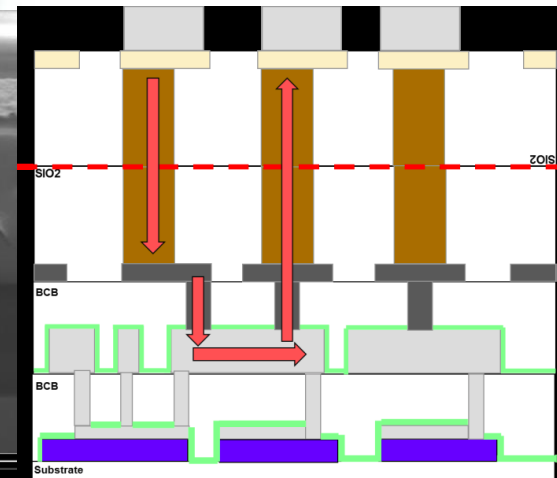
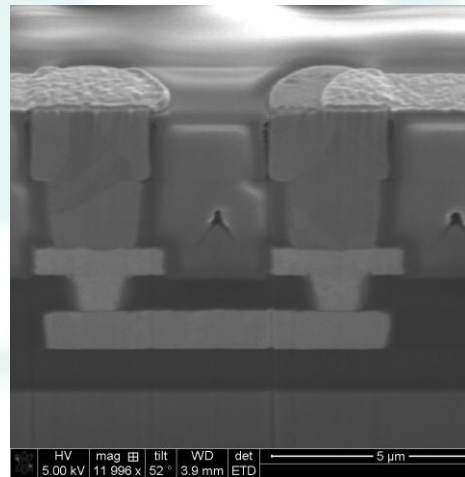
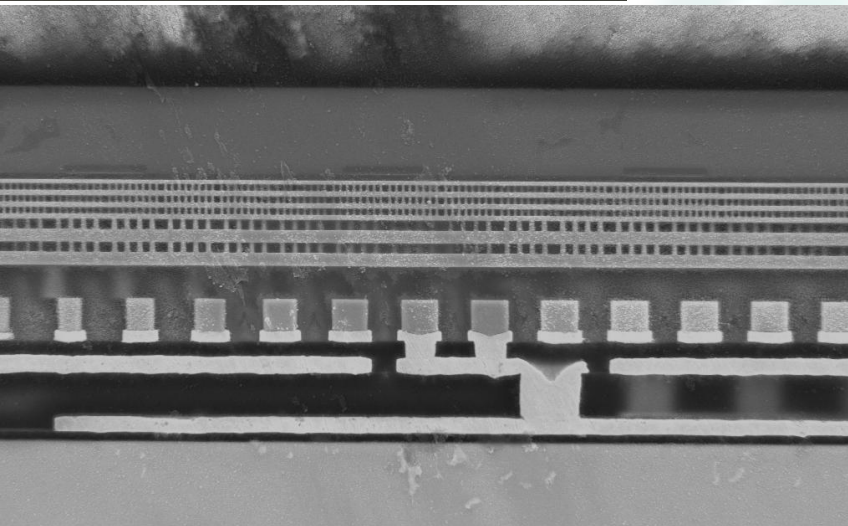
Si Interposers



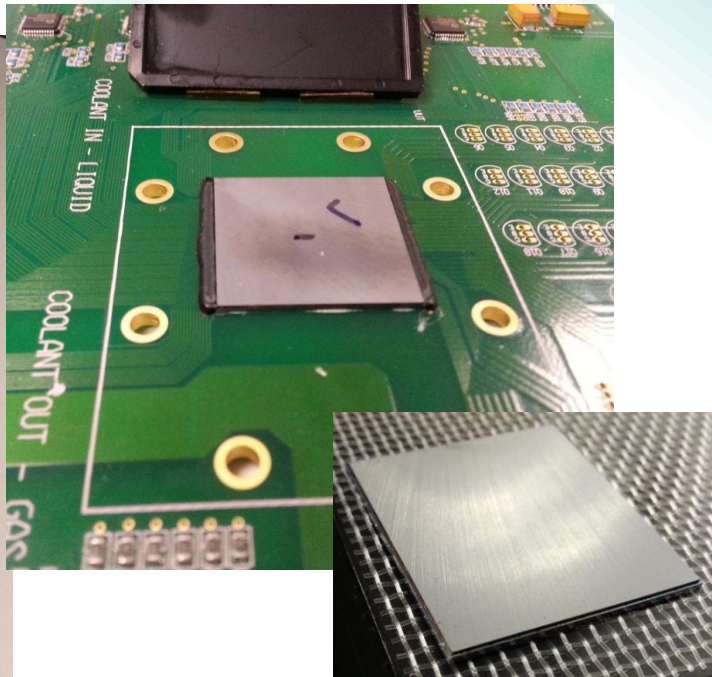
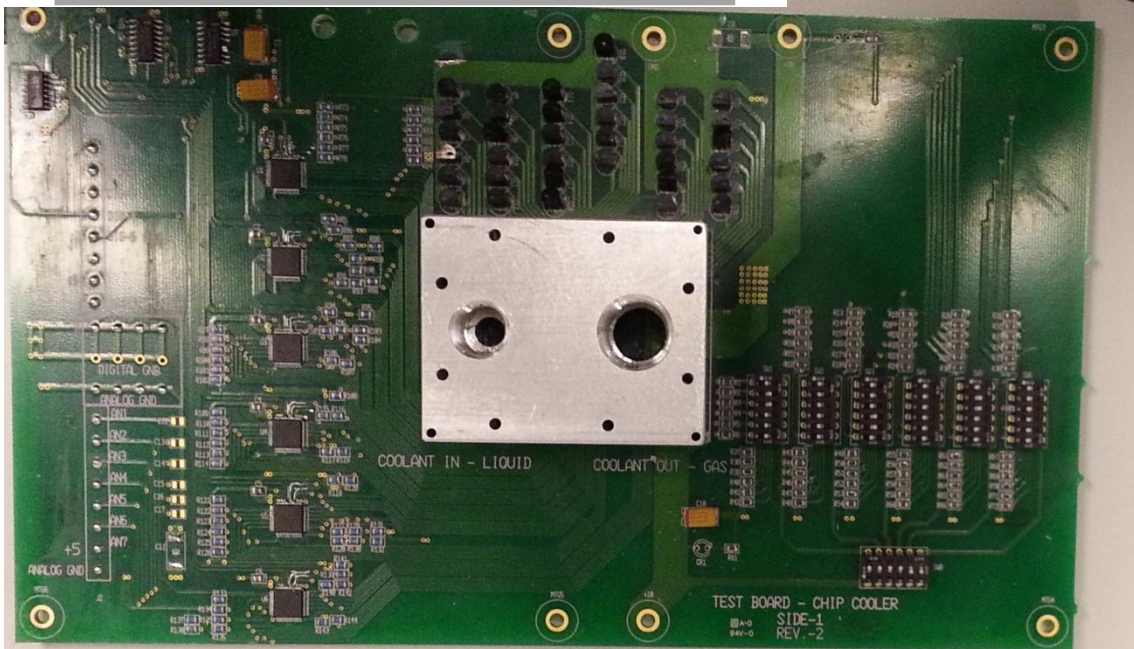
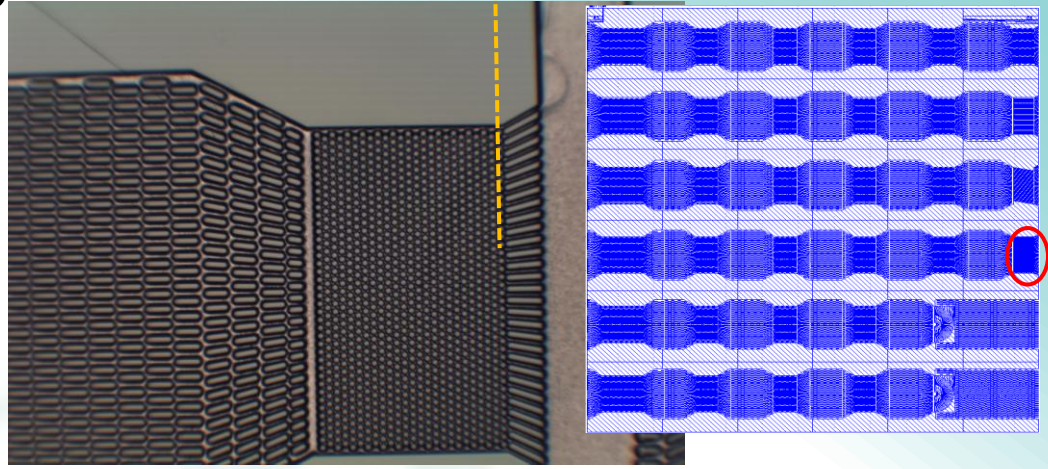
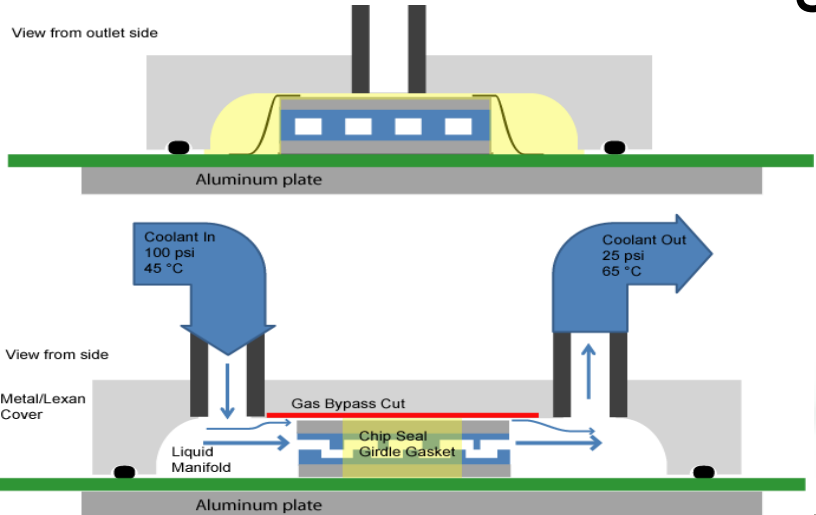
Mixed CMOS-3/5 100mm InP/CMOS



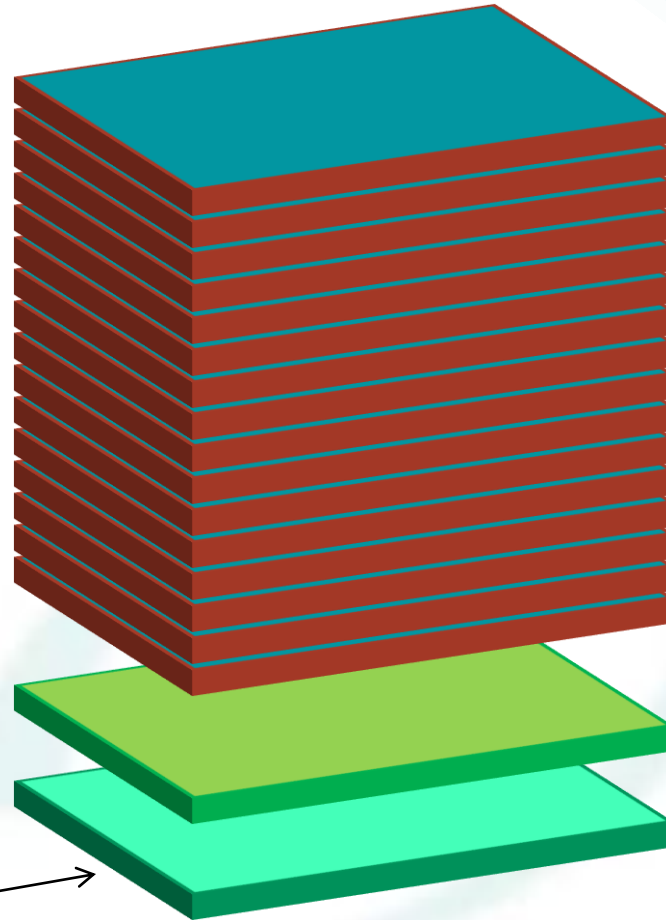
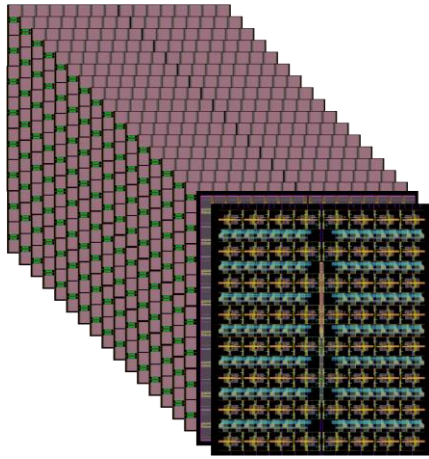
- GaN
- 3D CMOS/InP/GaN
- GaAs
- Graphene



Advanced 3D Cooling



DiRAM4 “Dis-Integrated” 3D Memory



DRAM layers
4xnm node

2 million vertical
connections per lay per
die

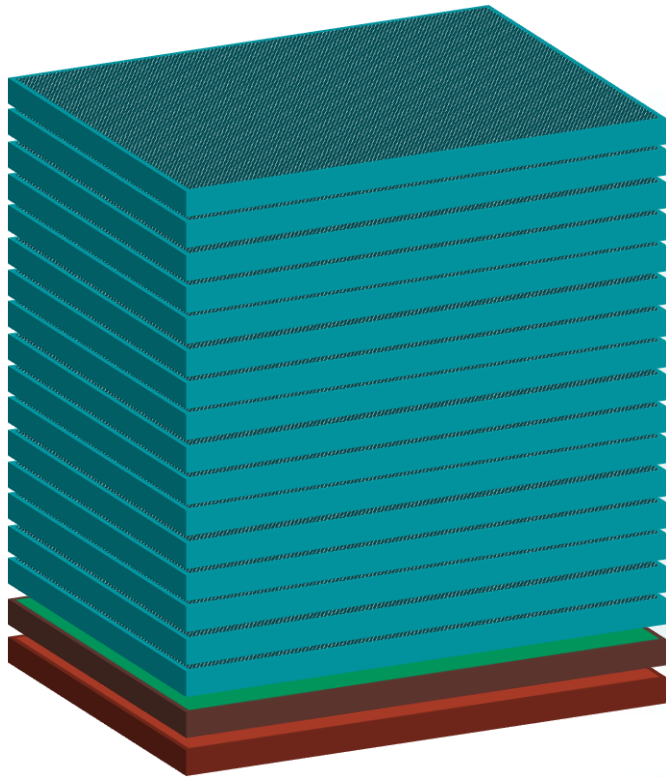
I/O layer contains: I/O,
interface logic and
R&R control CPU.

65nm node

Better yielding than 2D equivalent!

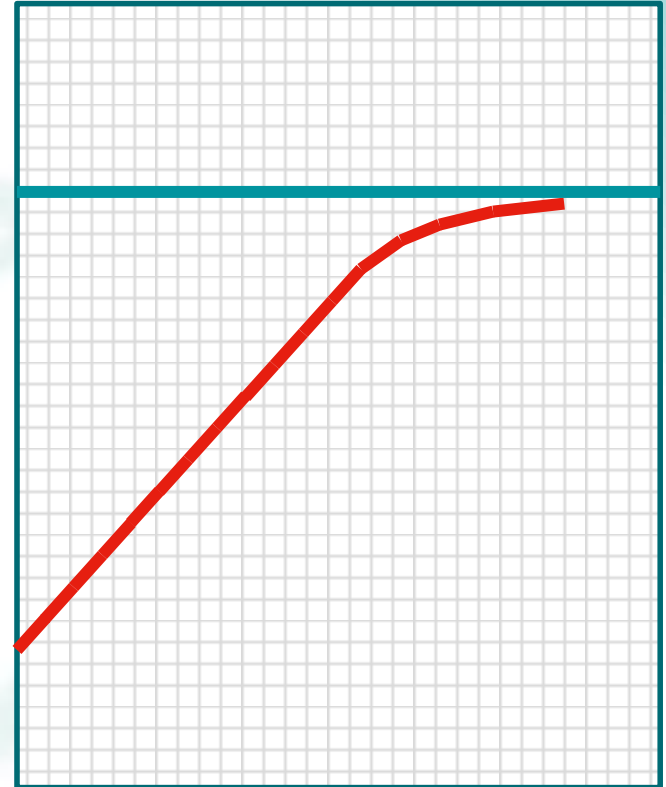
Controller layer
contains: sense amps,
CAMs, row/column
decodes and test
engines. 40nm node

Bi-STAR Repair Improves Yield



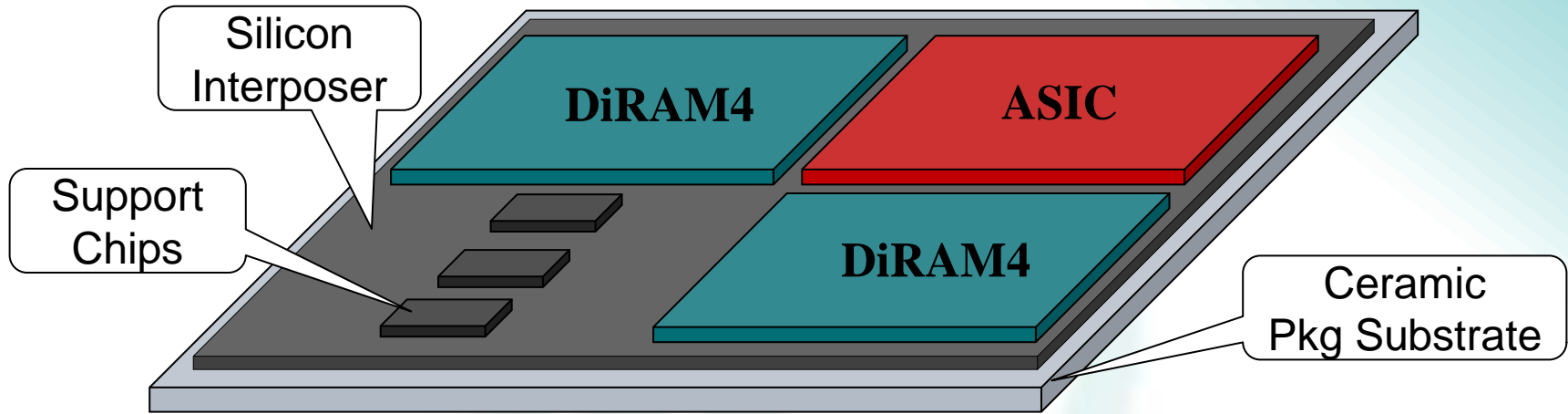
100%

Yield



Stack Height

HPC Processor Modules



Si Interposer-based Ceramic Package

e.g. DiRAM4 plus Custom Processor

50 μ - 100 μ pitch Copper Pillar Die-to-Interposer-to-Die Interconnect

~ 10000 Connections – Mostly die-to-die inside package

~250 μ pitch C4 Bump Interposer-to-Ceramic Package Substrate Interconnect

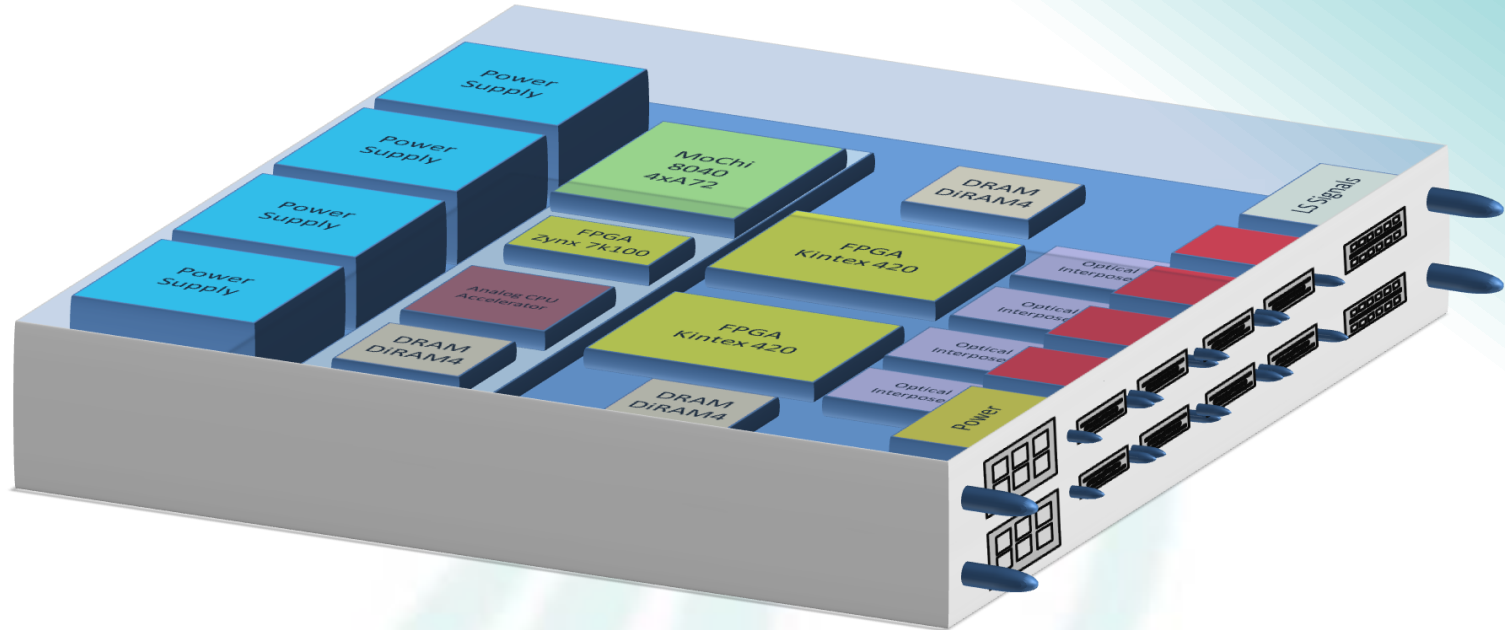
~ 2000 Connections – Lots of replicated power connections

1 mm pitch Solder Bump Package Substrate-to-Customer PCB Interconnect

Several Hundred of Connections

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And Full Subsystem Modules



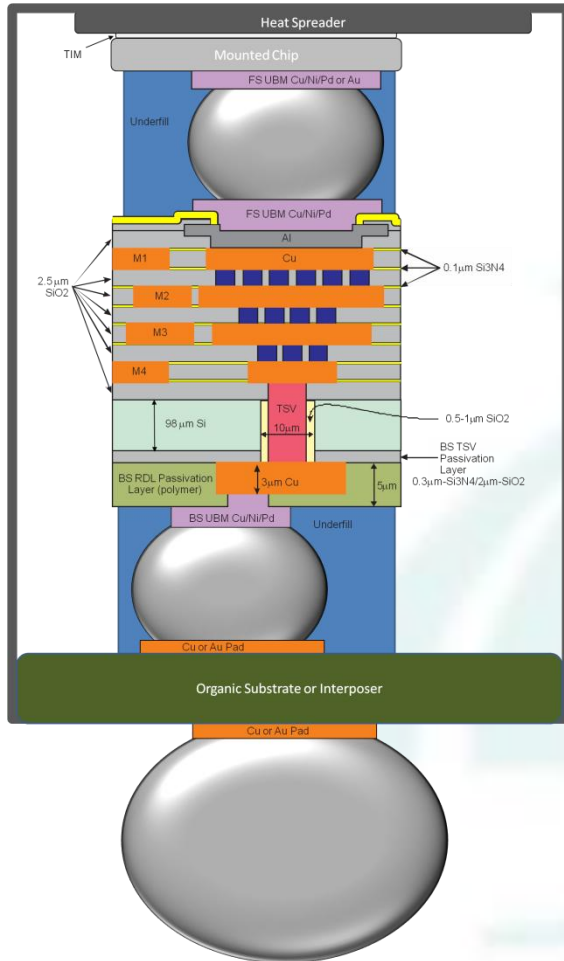
System Modules

Multiple Packages and /or Die

on High Performance Organic Interposer/Substrate with System Connectors

(Electrical: Card edge or Plugs, Optical: Fiber-optic Cable connectors)

Supply Chain



Donor Die
 Donor Die Bump
 Interposer UBM Topside
 Interposer
 Interposer UBM Bottomside
 Interposer Bump
 Interposer Underfill
 Donor Die Underfill
 Organic Substrate
 Substrate Bump
 TIM
 Package Lid
 Carrier Wafer
 Singulation
 Bond/Debond



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2.5/3D CHANGE IS HERE

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The Semiconductor Revolution

Samsung

16Gb NAND flash (2Gx8 chips),
Wide Bus DRAM, VNAND

Hynix
HBM DRAM

Intel

CPU + memory

Sony

CMOS Sensor

Xilinx

4 die 65nm interposer

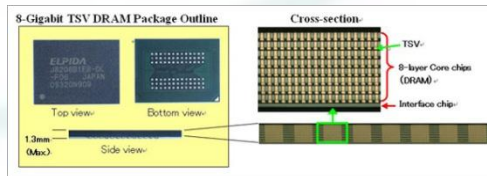
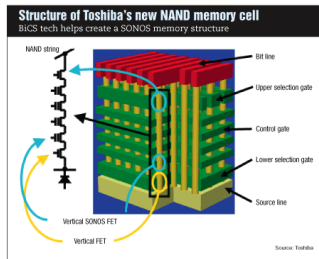
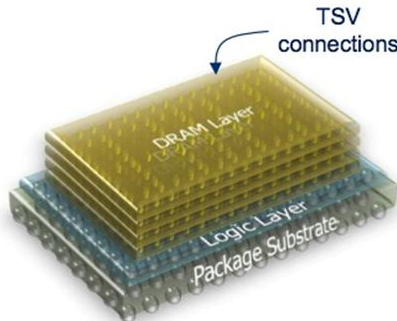
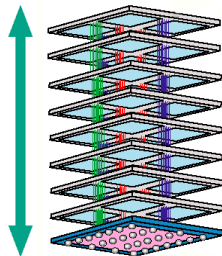
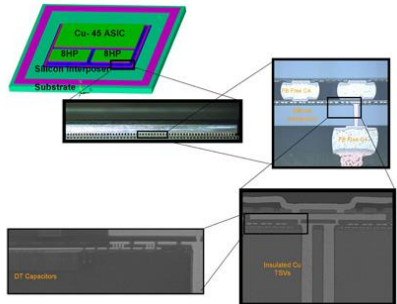
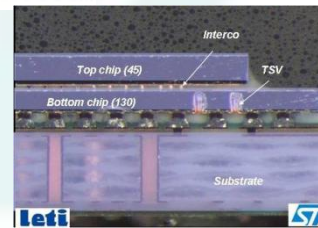
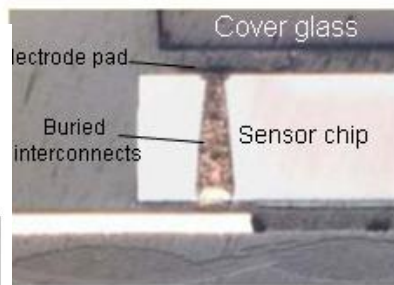
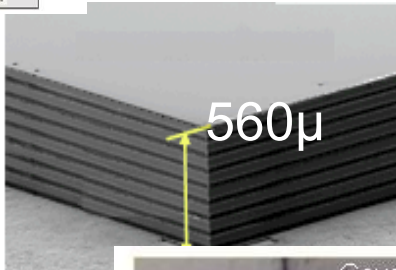
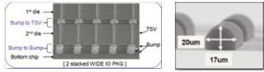
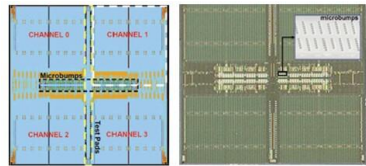
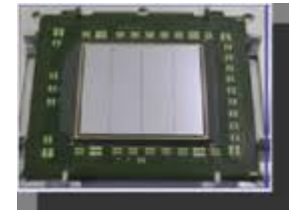
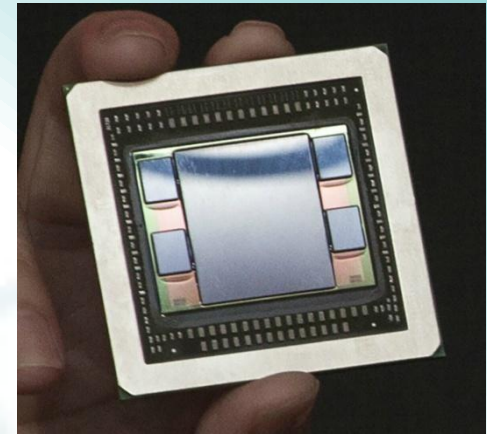
AMD

Radon R9

IBM

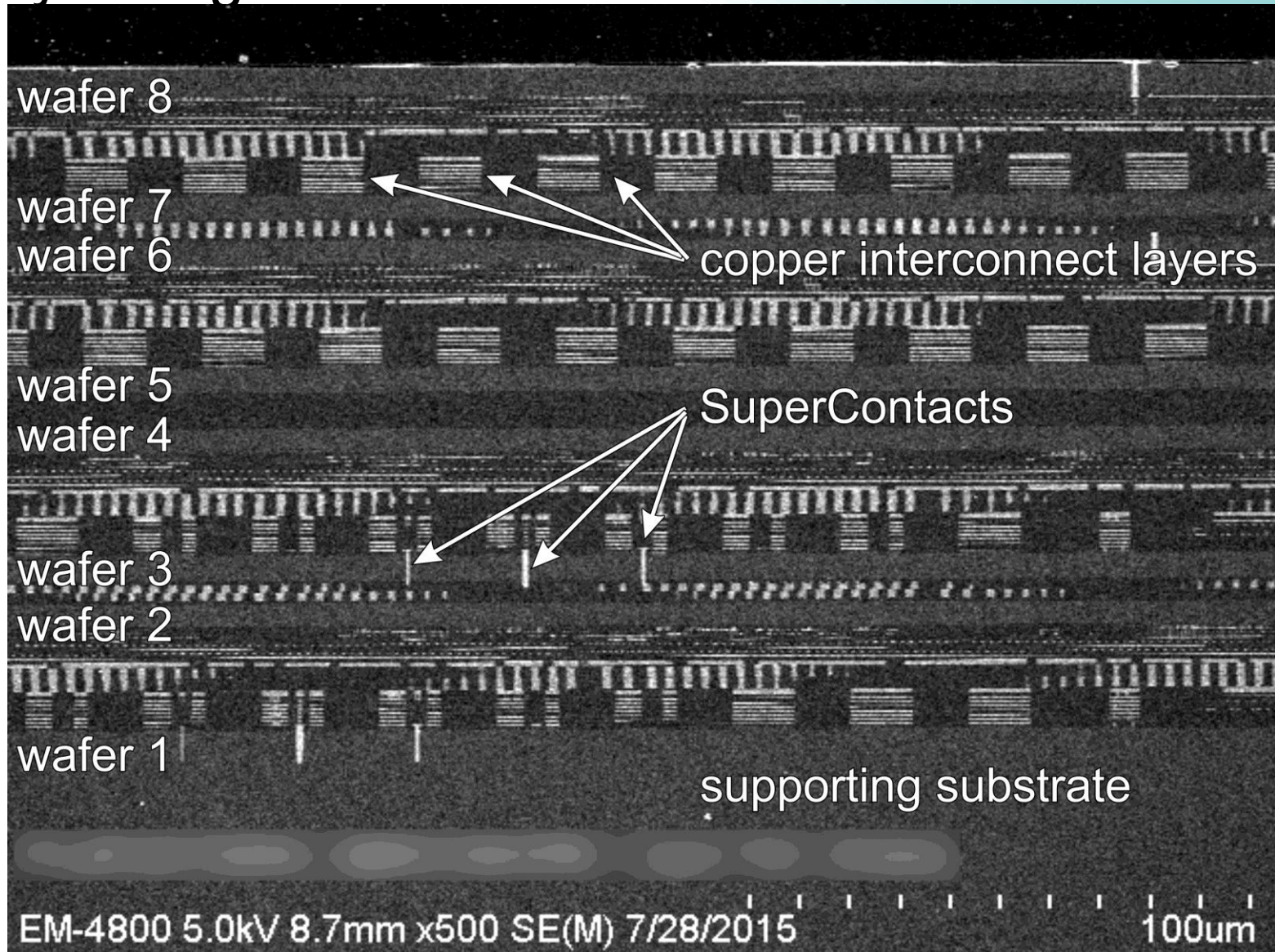
RF Silicon Circuit Board / TSV
Logic & Analog

Toshiba
3D NAND

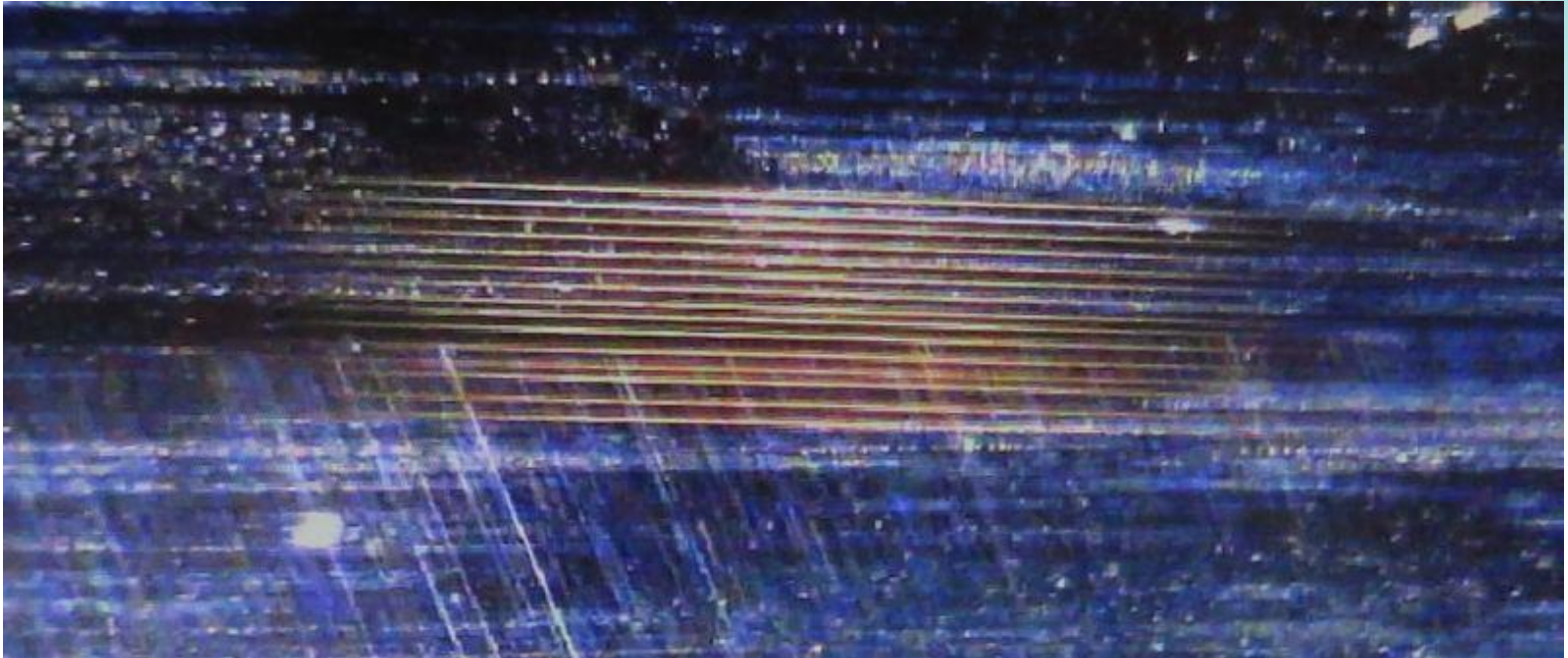


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8 Layer Logic Stack



16 Layer Mechanical Device Stack

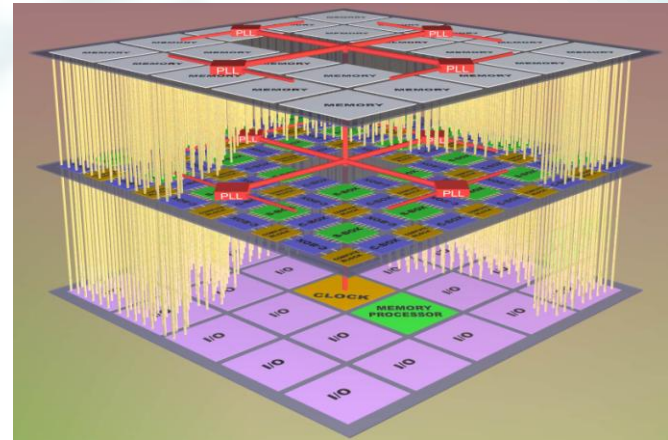


Bonding in Action



Summary

- 2.5/3D market is in the adoption cycle
 - Moving from novelty to mainstream
- Drivers are:
 - Heterogeneous integration
 - SWaP
 - Increasing performance
 - Lower system costs
- First markets are:
 - Logic – Memory
 - Sensors
- Significant industry shifts will happen
 - Silicon circuit cards with “Lego” blocks



Austin Facility Overview

- 110 Employees: 90 in Ops and Engineering
- Over 150 production grade tools
- 68,000 sq ft Class 10 clean room
- 24/7 operations & maintenance
- Manufacturing Execution Systems (MES)
- IP secure environments, robust quality systems
- ISO certified/ITAR registered
- Full-flow 200mm silicon processing, 300mm back-end (Copper/Low-k)
- Process library with > 25000 recipes
- Novel materials (ALD, PZT, III-V, etc)
- Copper & Aluminum BEOL
- Contact through 193nm & IR lithography
- Silicon, SOI and Transparent MEMS substrates
- Electrical Characterization and Bench Test Lab
- Onsite analytical tools and labs: SIMS, SEM, TEM, Auger, VPD, ICP-MS, etc

